

L Number	Hits	Search Text	DB	Time stamp
1	129429	plasma\$	USPAT	2002/10/02 10:42
2	153808	etch\$7	USPAT	2002/10/02 10:42
3	25519	plasma\$ with etch\$7	USPAT	2002/10/02 10:42
4	5377	"chf.sub.3"	USPAT	2002/10/02 10:52
5	1818	(plasma\$ with etch\$7) same "chf.sub.3"	USPAT	2002/10/02 10:43
6	1402	((plasma\$ with etch\$7) same "chf.sub.3") and (opening or viahole or hole or via or trench)	USPAT	2002/10/02 10:43
8	14	((plasma\$ with etch\$7) same "chf.sub.3") and (opening or viahole or hole or via or trench) and "c.sub.5 f.sub.8"	USPAT	2002/10/02 10:49
9	10	((plasma\$ with etch\$7) same "chf.sub.3") and (opening or viahole or hole or via or trench) and "c.sub.5 f.sub.8" and (align\$10 or sac)	USPAT	2002/10/02 10:50
10	4	((plasma\$ with etch\$7) same "chf.sub.3") same "c.sub.5 f.sub.8"	USPAT	2002/10/02 10:50
11	1	"chf.sub.3" same "c.sub.5 f.sub.8"	US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT	2002/10/02 10:52
7	71	"c.sub.5 f.sub.8"	USPAT	2002/10/02 12:19
12	5	Octafluoropentadiene	USPAT	2002/10/02 11:08
13	24778	fluorocarbon	USPAT	2002/10/02 11:09
14	2742	perfluorocarbon	USPAT	2002/10/02 11:14
15	13881	c?sub.\$	USPAT	2002/10/02 11:15
16	17310	f?sub.\$	USPAT	2002/10/02 11:16
17	42	c?sub.\$ adj1 f?sub.\$	USPAT	2002/10/02 11:17
18	3	(plasma\$ with etch\$7) and (c?sub.\$ adj1 f?sub.\$)	USPAT	2002/10/02 11:19
19	4	Octafluoropentadiene and (plasma\$ with etch\$7)	USPAT	2002/10/02 11:25
20	9731	"chf.sub.3" or trifluoromethane or trifluoro-methane or tri-fluoromethane or tri-fluoro-methane	USPAT	2002/10/02 11:26
21	26158	fluorocarbon or perfluorocarbon	USPAT	2002/10/02 11:26
22	553	("chf.sub.3" or trifluoromethane or trifluoro-methane or tri-fluoromethane or tri-fluoro-methane) same (fluorocarbon or perfluorocarbon)	USPAT	2002/10/02 11:26
23	330	((("chf.sub.3" or trifluoromethane or trifluoro-methane or tri-fluoromethane or tri-fluoro-methane) same (fluorocarbon or perfluorocarbon)) and (plasma\$ with etch\$7)	USPAT	2002/10/02 11:26
24	263445	semiconductor or semi-conductor or (semi adj1 conductor)	USPAT	2002/10/02 11:27
25	305	((("chf.sub.3" or trifluoromethane or trifluoro-methane or tri-fluoromethane or tri-fluoro-methane) same (fluorocarbon or perfluorocarbon)) and (plasma\$ with etch\$7)) and (semiconductor or semi-conductor or (semi adj1 conductor))	USPAT	2002/10/02 11:27
26	52	"c.sub.5 f.sub.8" and (semiconductor or semi-conductor or (semi adj1 conductor))	USPAT	2002/10/02 12:19

27	295	((("chf.sub.3" or trifluoromethane or trifluoro-methane or tri-fluoromethane or tri-fluoro-methane) same (fluorocarbon or perfluorocarbon)) and (plasma\$ with etch\$7)) and (semiconductor or semi-conductor or (semi adj1 conductor))) not ("c.sub.5 f.sub.8" and (semiconductor or semi-conductor or (semi adj1 conductor)))	USPAT	2002/10/02 12:20
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